

DERWENT- 2003-883257

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WEEK:

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TITLE: Sewing method of thick material e.g. wadded cloth used as trim cover, makes waste stitch closer to edge and lock stitch on inner side of the waste stitch

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PATENT-FAMILY:

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BASIC-ABSTRACT:

NOVELTY - A waste stitch (21) with a narrow sewing margin (B) is made by machine sewing of overlapped cloths (X,Y). A lock stitch (22) is formed along the inner side of waste stitch with a wider sewing margin (A).

USE - For wadded thick cloth used as trim cover.

ADVANTAGE - Enables reducing sewing margin, hence better fitting of trim cover after sewing is enabled, as the double seam compresses the evaded cloth.

DESCRIPTION OF DRAWING(S) - The figure is a sectional view of the sewn thick cloth.

waste stitch 21

lock stitch 22

wider sewing margin A

narrow sewing margin B

thick cloth to be sewn X,Y